

Thin Passive Components (TPC)

Passive Component Integration in Organic, Silicon and Glass Substrates

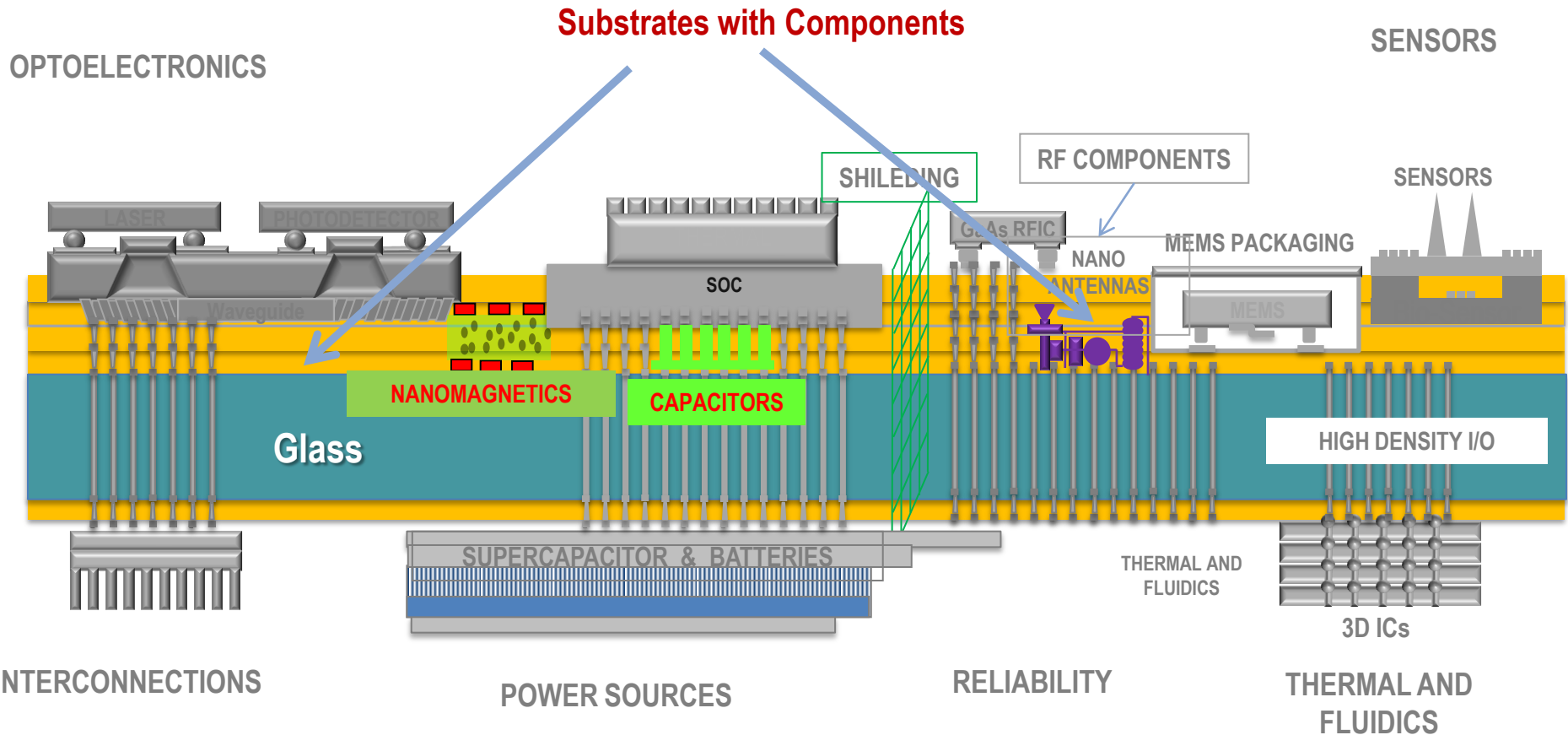
presented by

Dr. Venky Sundaram

Georgia Institute of Technology
3D-Systems Packaging Research Center

Atlanta, Georgia
May 25, 2011

Research Focus

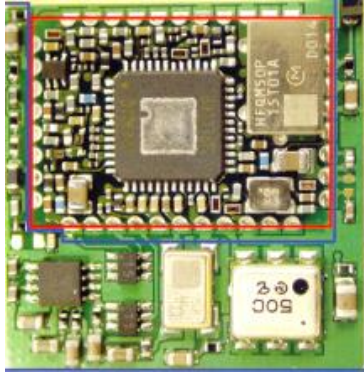


Passive Component Integration Objectives

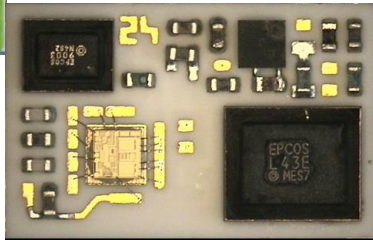
- Form factor reduction
 - X, Y and Z (<50 μ m)
 - Increasing drive to integrate passives at package level rather than board level
- BOM reduction
 - Multi-component IPDs and embedded passives
- Manufacturability and Cost
 - Testability
 - Reparability
 - Focus on high yielding processes



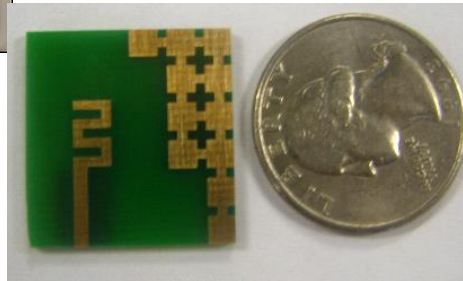
Passive Component Integration Options



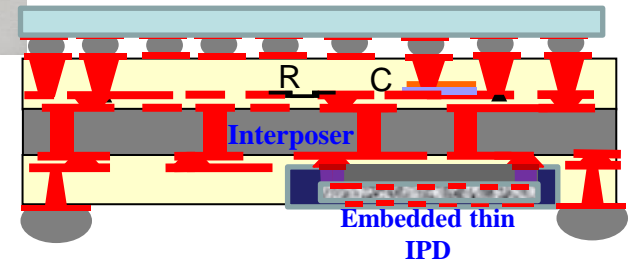
SMT
Discretes



Embedded
Ceramic



Embedded
Organic



TPC Focus – Si, Glass &
Organic IPDs or Embedding

Passive Integration Challenges

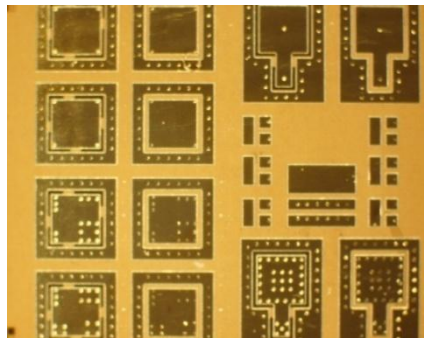
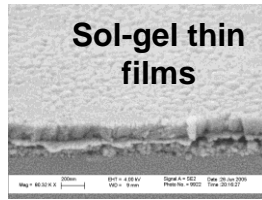
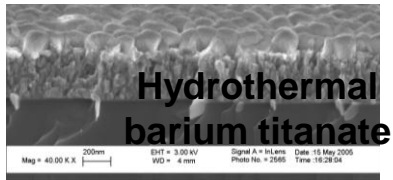
- **Limitations of Current Passive Components:**
 - Thickness incompatibility with thin substrate roadmap
 - 100s of microns to mm vs. organic substrates <200um
 - Area Density limited for ultra-thin form factors
 - Parasitics from interconnects (SMT at board or package level)
 - Pick and place cost for individual passive discrete components
- **Manufacturing Challenges for Integrated Passives:**
 - Low cost test
 - Lack of reparability for integrated passive components
 - Tunability at system level

Component Integration Approaches

- Ultra-Thin Glass or Silicon Interposer for integration of capacitors and magnetic components
- Substrate-compatible high precision RF components
- Embedded thin IPDs in the package substrate with testability and reparability

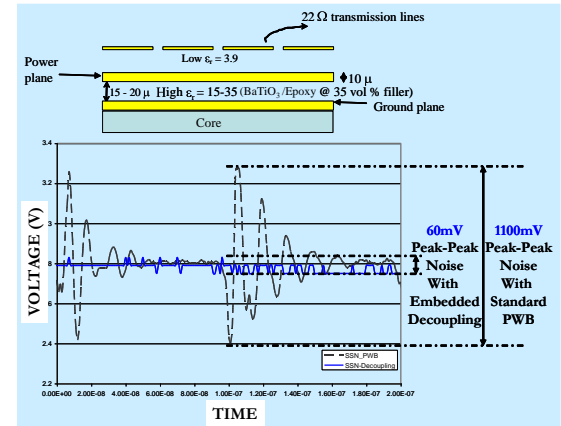


Background Research - Integration of Thin Film Decoupling Capacitors in Organic Substrates

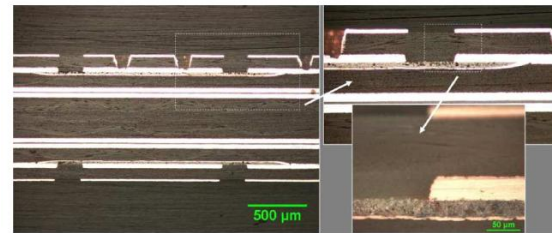


Large area demonstration of embedded thin film capacitors on organic board;

Nano-Composites & Nano-scale Thin Film High K Materials



Industry Prototypes System-Level Function Enhancement



DuPont

J. Amer. Ceram. Soc., August, , 93 (9), 2764-2770, 2010 ,

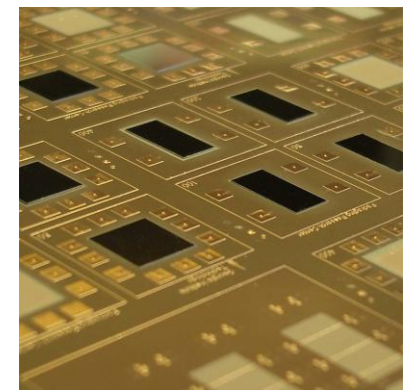
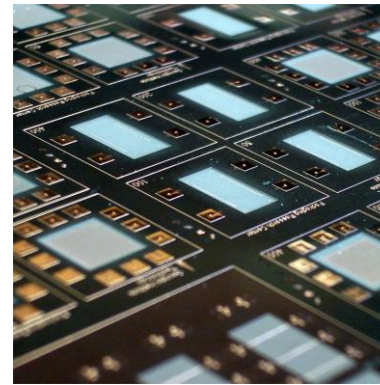
IEEE CPMT Transactions on Adv. Pkg, Dec. 2007, pp. 585-594.



Georgia Institute of Technology

Component-Last Embedding for Reparability

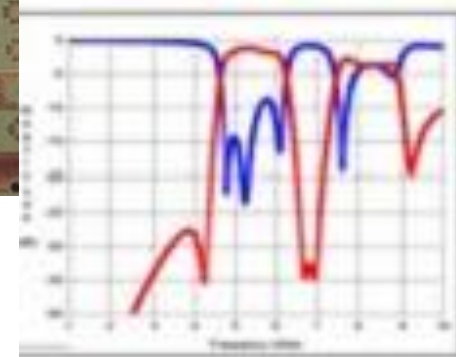
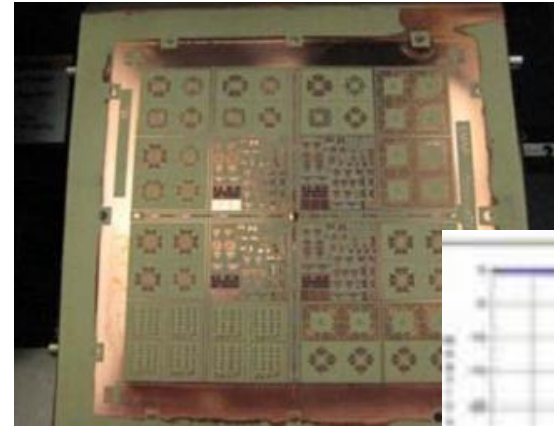
- Thin IPDs pre-tested
- Low Cost Panel Level Embedding
- Integration processes for:
 - No degradation in yield or electrical performance
 - Thermomechanical compatibility;



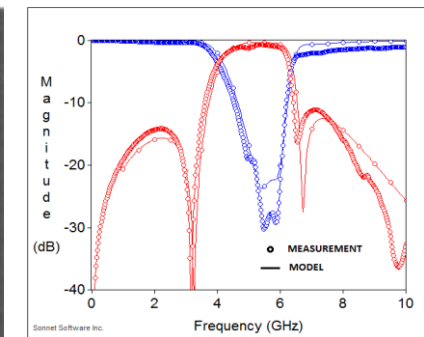
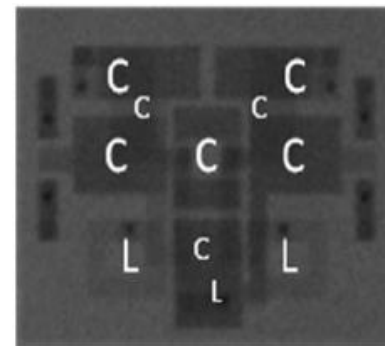
PRC's background in embedded thin discrettes

RF Component Integration

- Organic Substrates
 - Low loss up to 110GHz
 - FR-4 compatible process
 - Ultra-thin (<150 μ m)



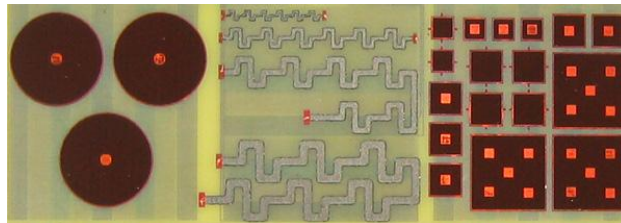
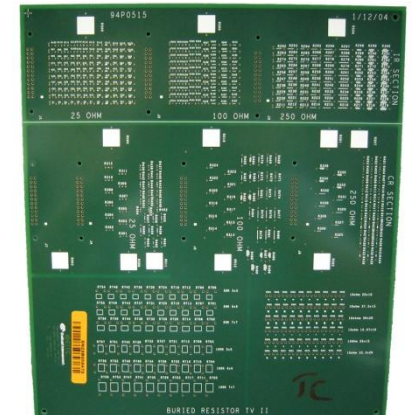
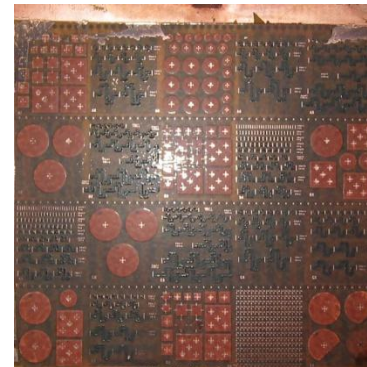
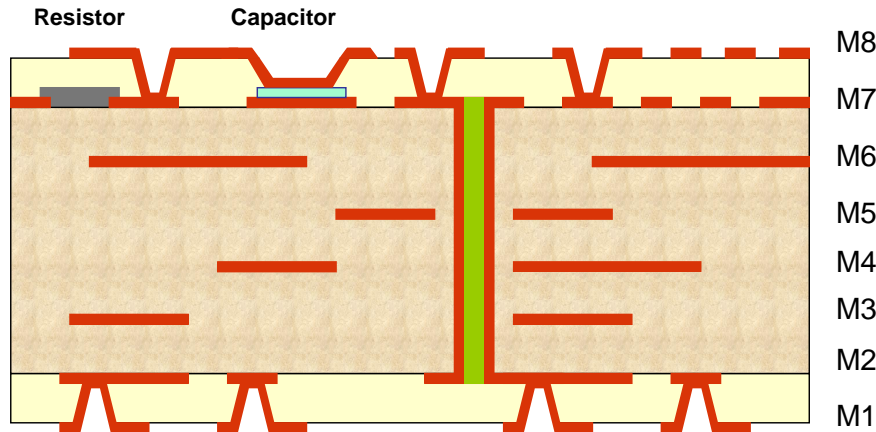
- Inorganic Substrates
 - High precision (<10 μ m lines/spaces)
 - Ultra-thin and low loss
 - High temperature process compatible



Insertion Loss ~ 0.72 dB

Industry Prototypes: Nokia Embedded R-C Test Vehicle

- Two year program to explore embedded passives for mobile phone integration



Test Cases	Temperature range	Soak Time	Humidity	Total Cycles/Hrs
Thermal Shock	-55 to 125 °C	10 minutes	N/A	1000 cycles
Temperature Humidity 1	85 °C	N/A	85 %	100 hours
Temperature Humidity 2	121 °C	N/A	100 %	



TPC Workshop

MAY 25, 2011

Thank you for attending.